What is claimed is:

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1. A film treatment apparatus, wherein a film of a coating solution coated on a substrate is gelatinized by using at least a second gas including a prescribed concentration of a vapor of prescribed solvent and a first gas, which comprises:

a chamber for placing said substrate coated with said film;

a first mass flow controller for supplying said chamber with said first gas;

a second mass flow controller for supplying said chamber with said second gas.

- The film treatment apparatus according to claim
 which further comprises:
- exhaust means for exhausting said chamber; and
 a chamber pressure control mechanism for detecting a
 pressure in said chamber, operating said exhaust means
 and controlling said pressure.
- 3. The film treatment apparatus according to claim 1, which further comprises:

a concentration sensor for measuring a concentration of said first gas in said chamber;

a pressure sensor for measuring a pressure in said chamber;

25 exhaust means for exhausting said chamber;

a chamber pressure control mechanism for operating said exhaust means on the basis of a measurement signal

from said pressure sensor and for controlling said pressure; and

a gas composition control mechanism for controlling said first or second mass flow controller on the basis of a measurement signal from said concentration sensor thereby keeping constant said concentration of said first gas.

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- 4. The film treatment apparatus according to claim 3, which further comprises a coating unit for coating a coating solution on a substrate and forming a film on said substrate.
- The film treatment apparatus according to claim
 wherein said second mass flow controller controls
 said second gas.
- 6. The film treatment apparatus according to claim
 1, which further comprises a mixer for mixing said
 first and second gases, wherein the mixed gas from said
 mixer is supplied into said chamber.
- 7. The film treatment apparatus according to claim
 3, wherein said chamber pressure control mechanism
 controls said pressure by controlling a throttle of an
 exhaust valve of said exhaust mechanism on the basis of
 a measurement signal from said pressure sensor.
 - 8. A film treatment method for gelatinizing a film of a coating solution coated on a substrate by using at least a second gas including a prescribed concentration of a vapor of prescribed solvent and a first gas, which

comprises the steps of:

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a first step for forming said film of a coating solution on said substrate;

a second step for transporting said substrate with said film into a treatment chamber; and

a third step for treating said film by supplying said treatment chamber with said first and second gases each of which flow is controlled by a respective mass flow controller.

9. A film treatment method for gelatinizing a film of a coating solution coated on a substrate by using at least a second gas including a prescribed concentration of a vapor of prescribed solvent and a first gas, which comprises the steps of:

a first step for forming said film of a coating solution on said substrate in an atmosphere of said second gas;

a second step for transporting said substrate with said film into a treatment chamber; and

a third step for treating said film by supplying said treatment chamber with said first gas through a mass flow controller and supplying said treatment chamber with said second gas.